

Notice of Allowability

Application No.

10/656,311

Applicant(s)

CHEN ET AL.

Examiner

Art Unit

Paul D. Kim

3729

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1. This communication is responsive to 11/3/2005.
2. The allowed claim(s) is/are 13,15,26,27,31-35,39-47 and 54.
3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) All b) Some* c) None of the:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

* Certified copies not received: _____.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.
THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.

4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.
(a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached
 1) hereto or 2) to Paper No./Mail Date _____.
(b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of
 Paper No./Mail Date _____.
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

Attachment(s)

1. Notice of References Cited (PTO-892)
2. Notice of Draftsperson's Patent Drawing Review (PTO-948)
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08),
 Paper No./Mail Date _____
4. Examiner's Comment Regarding Requirement for Deposit
 of Biological Material
5. Notice of Informal Patent Application (PTO-152)
6. Interview Summary (PTO-413),
 Paper No./Mail Date _____
7. Examiner's Amendment/Comment
8. Examiner's Statement of Reasons for Allowance
9. Other _____.

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Prejean on 11/16/2005.

The application has been amended as follows:

IN THE CLAIMS

Re. Claim 13: After the phrase "a high magnetic moment material" as recited in line 19, insert a phrase --by sputter depositing--.

After the phrase "wherein" as recited in line 24, change the phrase "forming the thin layer of high magnetic moment material" to --forming the layer of the high magnetic moment material on said first pole--.

Before the phrase "high magnetic moment material" as recited in line 25, change the phrase "a" to --the--.

Re. Claim 15: After the phrase "depositing" as recited in line 2, change the phrase "a mask" to --the mask--, and delete the phrase "on said plated magnetic moment material forming said second pole, said mask being disposed" as recited in lines 2-3.

Cancelled the claims 19, 21-25, 37, 38, 52 and 53.

Re. Claim 39: After the phrase "depositing" as recited in line 2, change the phrase "at least one" to --the--.

After the phrase "high magnetic moment material and" as recited in line 3, change the phrase "at least one" to --a--.

Re. Claim 54: After the phrase "depositing" as recited in line 24, change the phrase "a mask" to --the mask--, and delete the phrase "on said plated magnetic moment material forming said second pole, said mask being disposed" as recited in lines 24-25.

2. The following is an examiner's statement of reasons for allowance: The prior art of record fails to disclose the claimed invention. The closest reference, Ju et al., teaches a process of making a magnetic transducer including most of processes recited in the claimed invention, but Ju et al., fail to teach a process of forming a pedestal after the forming the first magnetic pole. Even though another closest reference, Chen et al., teaches a process of forming the pedestal, Chen et al. fail to teach the pedestal made of the high magnetic moment material including at least one lamina of a high magnetic moment material and at least one lamina of a non-magnetic dielectric material. Therefore, it would not be obvious to modify Ju et al. by adding a pedestal as taught by Chen et al. after the first pole is formed, since doing so would destroy the structure of the write head of Ju et al.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

3. Claims 13, 15, 26, 27, 31-35, 39-47 and 54 are allowed.

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Paul D. Kim whose telephone number is 571-272-4565.

The examiner can normally be reached on Monday-Friday between 7:00 AM to 3:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Peter Vo can be reached on 571-272-4690. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



Paul D Kim
Examiner
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